

Institute for Applied Materials **Applied Materials Physics**



Si(100)

Combined ferromagnetic and mechanical properties of Fe₃₂Co₄₄Hf₁₂N₁₂/TiN multilayer coatings for high frequency sensor applications

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Nowadays, as the state of the art, wear resistant coatings are used to extend the lifetime of mechanical components like, e.g., bearings or tools. As a new concept, we combine hardness with magnetic properties within a thin film multilayer system which consists of hard and ferromagnetic interface layers, in order to simultaneously develop the mechanical and magnetic properties as a functional sensor material.

This multilayer acts as a wear resistant coating, and due to the embedded ferromagnetic material it is possible to monitor an in situ temperature or strain induced stress which changes the magnetic properties like high frequency response.

We present the investigations of a new FeCoHfN/TiN multilayer system with regard to its hardness and ferromagnetic high frequency properties in comparison to FeCoHfN and TiN single layers, in order to obtain an appropriate sensor material.

Heat treatment:

Annealing for 1h at 600°C in a static magnetic field (50 mT) in vacuum after deposition

Inducing a uniaxial anisotropy H_U for a homogenous precession of magnetic moments in an external field

Sample preparation:

- Reactive dc and rf magnetron sputtering from a Fe₃₇Co₄₆Hf₁₇ and a Ti₅₀N₅₀ target in Ar and N₂ atmosphere with $N_2/A_r = 3\%$ and p = 0.2 Pa
- Alternating deposition of TiN and FeCoHfN single layers with modulation period $\lambda = 120$ nm





Ferromagnetic properties

Vibrating Sample Magnetometer



- and grain growth
- A marked uniaxial anisotropy field cannot be identified



Frequency dependent

- Initial permeability at low frequency μ_r = 135 is relatively low
- > Orientation of magnetic moments in one direction constrained by magnetocrystalline anisotropy
- Relatively high damping because of HfN phase which acts as scattering center





Mechanical properties

Residual stresses

Material	Treatment after deposition	Film thickness (µm)	σ (GPa)	•
Ti ₅₀ N ₅₀	as deposited	2.046	0.34 ± 0.10	-
Ti ₅₀ N ₅₀	1h@600°C	2.046	0.43 ± 0.06	
Fe ₃₂ Co ₄₄ Hf ₁₂ N ₁₂	as deposited	0.420	-1.11 ± 0.08	•
Fe ₃₂ Co ₄₄ Hf ₁₂ N ₁₂	1h@600°C	0.420	1.45 ± 0.17	
Fe ₃₂ Co ₄₄ Hf ₁₂ N ₁₂ /Ti ₅₀ N ₅₀	as deposited	0.904	$\textbf{-2.66} \pm 0.09$	٠
$Fe_{32}Co_{44}Hf_{12}N_{12}/Ti_{50}N_{50}$	1h@600°C	0.904	0.13 ± 0.15	

- Compressive stress due to growth conditions during the sputtering process for FeCoHfN single layer
- Large mismatch between lattice constants of TiN and FeCo results in very high compressive stress for the as deposited FeCoHfN/TiN multilayer
- After annealing stress becomes tensile because of different
- thermal expansion coefficients of layers and substrate
- Lowest stress for annealed multilayer

Hardness and reduced Young's modulus

Material	Treatment after deposition	Film thickness (µm)	H (GPa)	<i>E_r</i> (GPa)
Ti ₅₀ N ₅₀	as deposited	1.548	18.5 ± 1.4	205.0 ± 5.3
Fe ₃₂ Co ₄₄ Hf ₁₂ N ₁₂	as deposited	0.420	10.8 ± 3.5	119.6 ± 3.3
Fe ₃₂ Co ₄₄ Hf ₁₂ N ₁₂ /Ti ₅₀ N ₅₀	as deposited	0.904	14.6 ± 1.9	160.1 ± 4.6
Fe ₃₂ Co ₄₄ Hf ₁₂ N ₁₂ /Ti ₅₀ N ₅₀	1h@600°C	0.904	17.2 ± 1.2	175.1 ± 4.0

- Hardness of as deposited multilayer is in good agreement with the rule of mixture value (H = 15.3 GPa)
- As a result of annealing the hardness of the multilayer approaches nearly the value of TiN

$Fe_{32}Co_{44}Hf_{12}N_{12}/TiN$ multilayer coating:

- Resonance frequency above 2 GHz
- Stress induced changes in high frequency response could be measured
- Mechanical hardness of the annealed multilayer near the value of TiN
- Very small residual stresses after annealing



Conclusions

Hardness and ferromagnetic high frequency properties could be combined in one functional Fe₃₂Co₄₄Hf₁₂N₁₂/TiN material system

References

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